ASHURST et al., Application No. 10/086,652 Examiner: Markham, W.D.; Art Unit 1762

Amendment No. 1: Reply to Office Action of November 14, 2003

AMENDMENTS TO THE CLAIMS

The following is a complete set of claims for this application, replacing all prior versions:

- 1 Claim 1 (currently amended): A method for applying a silane coating to a surface that is
- 2 at least partially wettable by water, said method comprising exposing said surface to a vapor-
- 3 phase dihalodi(C₁.C₃ alkyl)silane and water vapor, in a non-oxidizing atmosphere at a total
- 4 pressure of 10⁻¹² torr to 100 torr under conditions resulting in the bonding of di(C₁-C₃
- 5 alkyl)silyloxy groups to said surface.
- 1 Claim 2 (original): A method in accordance with claim 1 in which said dihalodi(C₁-C₃
- 2 alkyl)silane is $di(C_1-C_3 \text{ alkyl})dichlorosilane.$
- 1 Claim 3 (original): A method in accordance with claim 1 in which said dihalodi(C₁-C₃
- 2 alkyl)silane is dimethyldichlorosilane.
- 1 Claim 4 (original): A method in accordance with claim 1 in which said surface is a
- 2 hydrophilic surface.
- 1 Claim 5 (original): A method in accordance with claim 1 in which said surface is a member
- 2 selected from the group consisting of hydroxyl-terminated silicon, silicon nitride, glass, steel,
- 3 alumina, oxides of copper, and oxides of gold.
- 1 Claim 6 (original): A method in accordance with claim 1 in which said surface is hydroxyl-
- 2 terminated polysilicon.
- 1 Claim 7 (canceled)
- 1 Claim 8 (canceled)

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- 1 Claim 9 (currently amended): A method in accordance with claim 1 in which said
- 2 $\underline{\text{dihalodi}(C_1-C_3 \text{ alkyl})\text{silane is dichlorodi}(C_1-C_3 \text{ alkyl})\text{silane and said method comprises}}$
- 3 comprising exposing said surface to a gaseous mixture consisting of said dichlorodi(C₁-C₃
- 4 alkyl)silane, water vapor and an inert gas.
- 1 Claim 10 (currently amended): A method in accordance with claim 1 in which said
- 2 $\underline{\text{dihalodi}(C_1-C_3 \text{ alkyl})\text{silane is dichlorodi}(C_1-C_3 \text{ alkyl})\text{silane and said method comprises}}$
- 3 comprising exposing said surface to a gaseous mixture consisting of said dichlorodimethylsilane.
- 4 water vapor and molecular nitrogen.
- 1 Claim 11 (original): A method in accordance with claim 1 in which said vapor-phase
- 2 dihalodi(C₁-C₃ alkyl)silane is at a partial pressure of from about 0.5 torr to about 5.0 torr.
- 1 Claim 12 (original): A method in accordance with claim 1 in which said dihalodi(C₁-C₃
- 2 alkyl)silane is dichlorodimethylsilane and is at a partial pressure of from about 1.0 torr to about
- 3 3.0 torr.
- 1 Claim 13 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 at a total pressure of from about 0.1 torr to about 15 torr.
- 1 Claim 14 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 at a total pressure of from about 1 torr to about 5 torr.
- 1 Claim 15 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 at a temperature of from about 0°C to about 85°C.
- 1 Claim 16 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 at a temperature of from about 15°C to about 50°C.
- 1 Claim 17 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 for a continuous exposure time of from about 3 minutes to about 30 minutes.

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PATENT

- 1 Claim 18 (original): A method in accordance with claim 1 in which said exposure is performed
- 2 for a continuous exposure time of from about 10 minutes to about 20 minutes.
- 1 Claim 19 (new): A method in accordance with claim 1 in which said surface has exposed
- 2 hydroxyl groups.
- 1 Claim 20 (new): A method in accordance with claim 19 in which said surface is hydroxyl-
- 2 terminated silicon.
- 1 Claim 21 (new): A method in accordance with claim 19 in which said surface is hydroxyl-
- 2 terminated polysilicon.